crystals with dimensions of several millimeters were cleaved from these ingots. The cleaved slices were transparent, pale yellow in color, and about 1 mm thick. Optical and electrooptical effects observed were visible luminescence at 77 °K under uv excitation, photoconductivity, and photovoltaic effects. The photoconductive and photovoltaic measurements were made on unetched, unpolished slices using indium and/or silver electrodes. The dark resistivity value determined from the dimensions of the crystal and from the voltage-current relations at from temperature was  $10^8~\Omega\text{-cm}$  along the C axis, and  $10^8~\Omega\text{-cm}$  perpendicular to it.

Photoconductive measurements were made using crystals with indium contacts soldered to sides parallel to the C axis. The experimental arrangement is shown schematically in Fig. 2. A typical room temperature photoconductive spectral response for constant irradiant power on the detector is shown in Fig. 3 (curve A). The constant irradiant power was maintained by varying the slit width with wavelength. At the peak of the response curve the resolution was 80 Å. The room temperature noise equivalent power (NEP) at 0.534  $\mu$  was 5.3  $\times$  10<sup>-10</sup> W. The photoconductive response at 77°K is shown in curve B of Fig. 3. These results are qualitatively like those obtained with water grown crystals.\(^1\) If a linear relationship is assumed between the position of the peak response and the temperature, the slope would be 1.32 Å/°C. The photoconductive time constant was I msec. This value was obtained by measuring the frequency dependence of the signal voltage.

Photovoltaic elements were made with both evaporated indium and with silver contacts on a crystal. In order to isolate the voltage due to a given contact, a cell geometry similar to that used by Fabricius² was employed (see inset Fig. 4). The semitransparent electrode had a transmission of about 60% and was evaporated onto a face perpendicular to the C axis. The experimental arrangement was the same as for the photoconductive measurements except that no bias was used, and the electrometer was operated as an impedance matching amplifier. The room temperature spectral response is shown in Fig. 4, and is seen to be quite similar to the photoconductive response. The photovoltaic peak occurs at  $0.531~\mu$ , where the NEP was  $7.2\times10^{-10}$  W.

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## A Screenless Integrating Sphere

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Integrating spheres seem to be the best available differential are practically mandatory when near-perfect diffuse radio beautiful required, as in densitometry. Besides the wall of the explication the major sources of nonuniformity are due to the necessity of introducing radiation into the sphere. This requires an entrance port and, usually, a focal spot on the opposite side of the sphere. Both represent nonuniformities in the sphere wall luminance and therefore, must be shielded from the exit port. The required shielding screens are, at best, inconvenient. In the present communication, a method is proposed for constructing a diffusing sphere requiring no screens.

It has been suggested? that the use of an opal glass window at

the entrance port would permit the introduction of a greate amount of diffuse flux with a limited entrance port diameter. I would also eliminate the focal spot. We show that, with thi method, the proper choice of port area yields a window luminance identical to that of the sphere wall.

When the exit port is small compared with the sphere diameter the sphere wall emittance is 3

$$M = [\rho/(1-\rho)]\Phi/4\pi r^2$$

where  $\rho$  is the sphere reflectance,  $\Phi$  is the total entering flux, and r is the sphere radius.

At the entrance port, the emittance is somewhat lower because of the lower reflectivity of the window  $\rho_w$ , but higher owing to the entering flux. It may be written

$$M_w = \frac{\rho_w}{1-\rho} \frac{\Phi}{4\pi r^2} + \frac{\Phi}{A_w} = \frac{\Phi}{\pi} \left[ \frac{1}{r_w^2} + \frac{\rho_w}{4(1-\rho)r^2} \right].$$

where  $A_{\sigma}$ ,  $r_{\sigma}$  are the window area and radius, respectively. The excess emittance at the entrance window is, then,

$$\Delta M = M_{\odot} - M = \frac{\Phi}{\pi} \left[ \frac{1}{r_{w}^{2}} - \frac{\rho - \rho_{w}}{4(1 - \rho)r^{2}} \right].$$

This excess luminance vanishes when  $r/r_w = [(\rho - \rho_w)/4(1 - \rho_w)]^{1/2}$ .

Unfortunately, this expression will lead to the desired large ratio only for very small values of  $1 - \rho$ . However, values of  $\rho = 0.995$  have been measured.<sup>4</sup> With this value, and  $\rho_{\varphi} = 0.55$ , the required ratio is  $r/r_{\psi} = 4.617$ , which makes the part area  $\frac{1}{2}$  of the sphere area.

This work was carried out for Newtek, Incorporated, 2200 Shames Drive, Westbury, New York.

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## Use of Cer-Vit Material in Low Expansion Reference Optical Cavities

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Passive optical cavities have been employed as sensing the criminators in fast response laser frequency counted system. The frequency stability of the laser is then determined by the chability of the reference cavity. If the cavity the character is bancally rigid and well shielded from ambient pressure to chances, the short term stability of the laser can be very bight setter than 1 part in  $10^{10}$ ); however, the long term stability of the frequence cavity the paper. The long term trequency stability,  $\Delta \nu/\nu$ , is given that  $\nu = \alpha \Delta T$ , where  $\nu = \alpha \Delta T$  is the spacer expansion coefficient and the stability of 1 part in  $10^{9}$  with a fused silical spacer ( $\alpha = 5.7 \times 10^{9}$ ,  $\Delta T$  must be controlled to within  $\pm 0.0003^{\circ}$ C. Cell-Viff a low expansion material recently available from Owens-Illinos thas Company, appears promising as a replacement for fused silical in this application. According to